

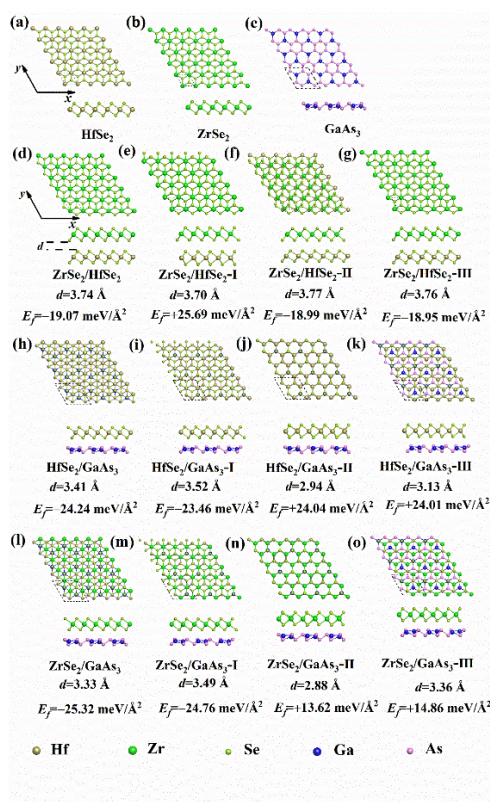
## Supporting Information

# Efficient photocatalytic hydrogen evolution and CO<sub>2</sub> reduction by HfSe<sub>2</sub>/GaAs<sub>3</sub> and ZrSe<sub>2</sub>/GaAs<sub>3</sub> heterostructures with direct Z-schemes

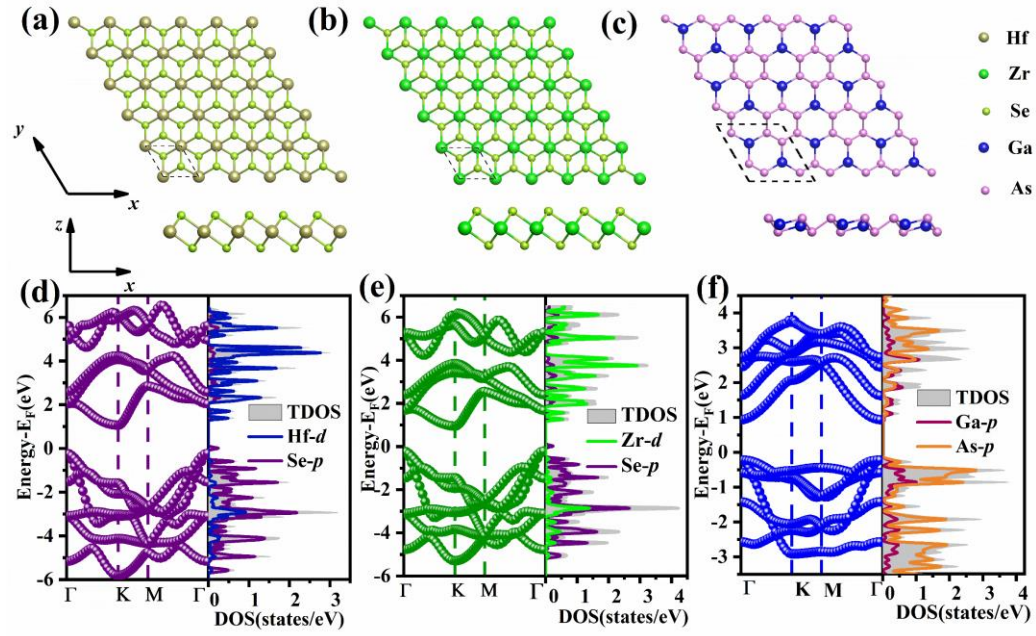
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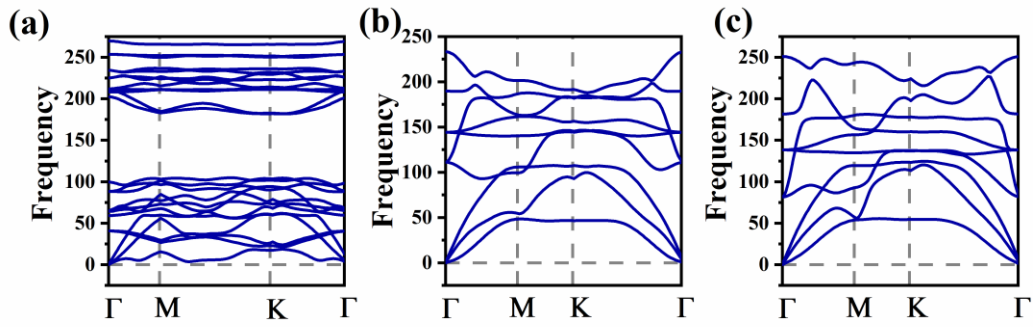
## 1. The geometrical configurations and electronic properties of the monolayers and heterostructures



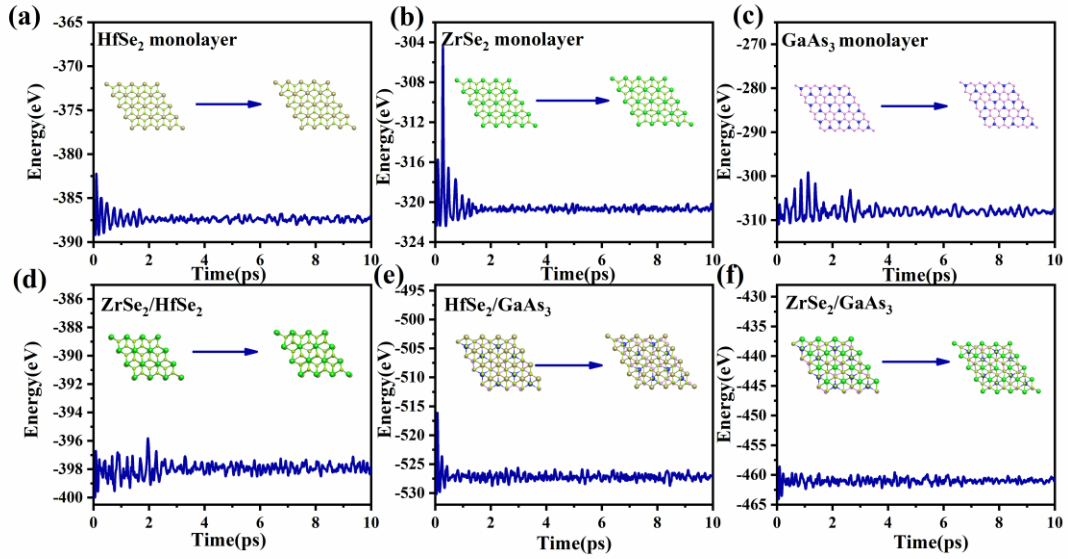
**Fig. S1** The top and side views of the monolayers. (a)-(c), the HfSe<sub>2</sub>, ZrSe<sub>2</sub>, and GaAs<sub>3</sub> monolayers. The top views, side views, formation energies ( $E_f$ ) and interlayer distances ( $d$ ) of the heterostructures. (e)-(o), the ZrSe<sub>2</sub>/HfSe<sub>2</sub>, ZrSe<sub>2</sub>/HfSe<sub>2</sub>-I, ZrSe<sub>2</sub>/HfSe<sub>2</sub>-II, ZrSe<sub>2</sub>/HfSe<sub>2</sub>-III, HfSe<sub>2</sub>/GaAs<sub>3</sub>, HfSe<sub>2</sub>/GaAs<sub>3</sub>-I, HfSe<sub>2</sub>/GaAs<sub>3</sub>-II, HfSe<sub>2</sub>/GaAs<sub>3</sub>-III, ZrSe<sub>2</sub>/GaAs<sub>3</sub>, ZrSe<sub>2</sub>/GaAs<sub>3</sub>-I, ZrSe<sub>2</sub>/GaAs<sub>3</sub>-II and ZrSe<sub>2</sub>/GaAs<sub>3</sub>-III heterostructures.



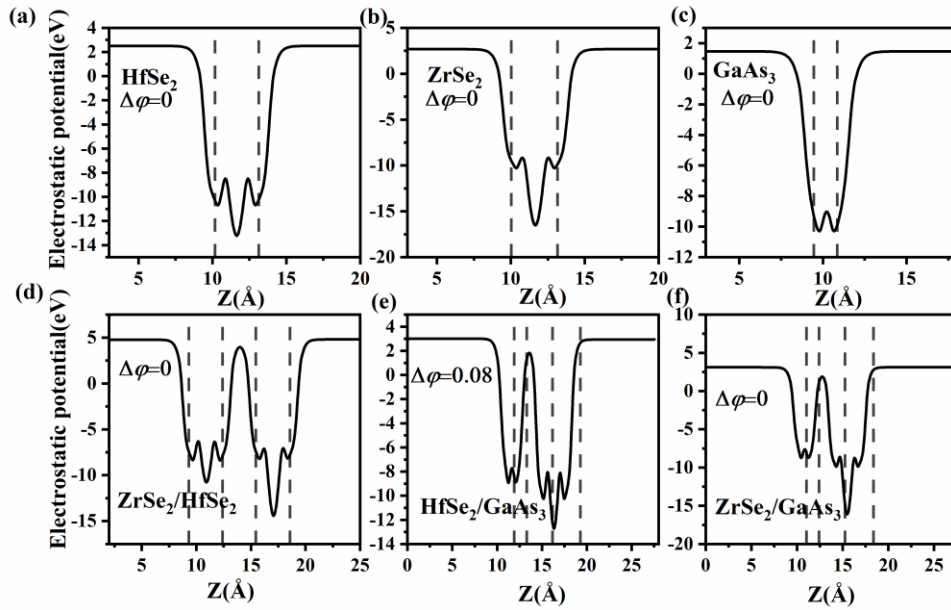
**Fig. S2.** The geometrical structures and the band structures of the (a) (d)HfSe<sub>2</sub>, (b) (e) ZrSe<sub>2</sub> and (c) (f) GaAs<sub>3</sub> monolayers. The Fermi level is set to zero.



**Fig. S3.** The phonon dispersions of considered monolayers. (a) GaAs<sub>3</sub>, (b) HfSe<sub>2</sub> and (c) ZrSe<sub>2</sub>.



**Fig. S3.** The AIMD simulation results in a temperature of 300 K for the considered structures. (a) HfSe<sub>2</sub>, (b) ZrSe<sub>2</sub>, (c) GaAs<sub>3</sub>, (d) ZrSe<sub>2</sub>/HfSe<sub>2</sub>, (e) HfSe<sub>2</sub>/GaAs<sub>3</sub> and (f) ZrSe<sub>2</sub>/GaAs<sub>3</sub>.



**Fig. S5.** The electrostatic potentials and the vacuum levels of the monolayers and the considered heterostructures. (a) HfSe<sub>2</sub>, (b) ZrSe<sub>2</sub>, (c) GaAs<sub>3</sub>, (d) HfSe<sub>2</sub>/GaAs<sub>3</sub>, (e) HfSe<sub>2</sub>/GaAs<sub>3</sub> and (f) ZrSe<sub>2</sub>/GaAs<sub>3</sub>.

**Table. S1.** The lattice constants, bandgaps, CBMs and VBMs calculated by HSE06 for HfSe<sub>2</sub>, ZrSe<sub>2</sub> and GaAs<sub>3</sub> monolayers.

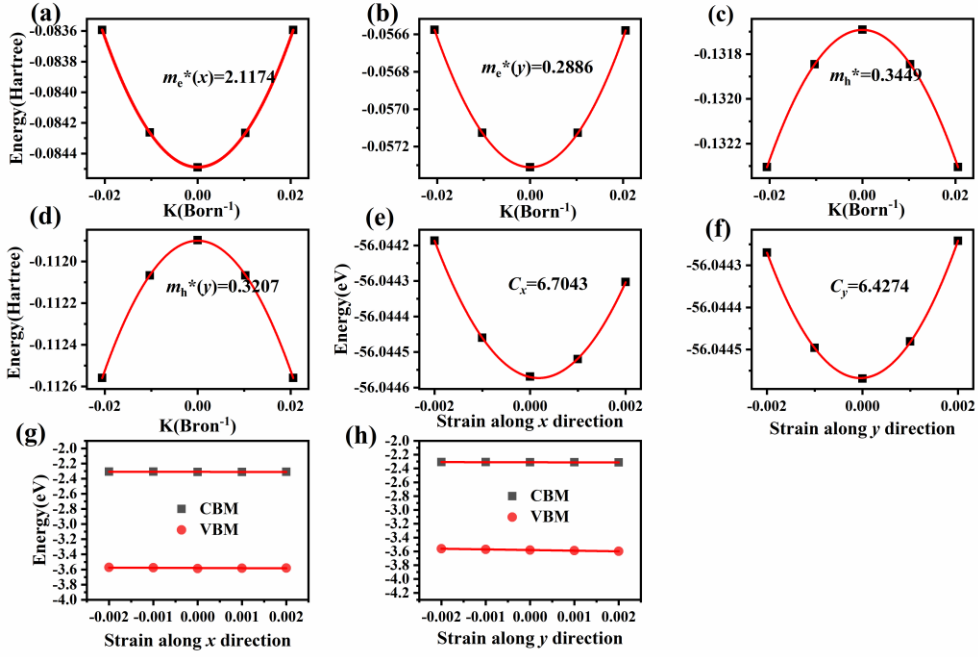
Monolayer	$a$ (Å)	$a$ (Å) (Exp./Cal.)	$E_g$ (eV)	$E_g$ (eV) (Exp./Cal.)	CBM (eV)	VBM (eV)
HfSe <sub>2</sub>	3.73	3.78 <sup>1</sup> ,3.70 <sup>2</sup>	1.28	1.10 <sup>1</sup> ,1.30 <sup>3</sup>	-4.80	-6.09
ZrSe <sub>2</sub>	3.76	3.77 <sup>4,5</sup>	1.15	1.20 <sup>6</sup> ,1.18 <sup>7</sup>	-4.99	-6.15
GaAs <sub>3</sub>	7.52	-----	1.16	-----	-4.26	-5.42

## 2. Details and calculational results of the carrier mobility

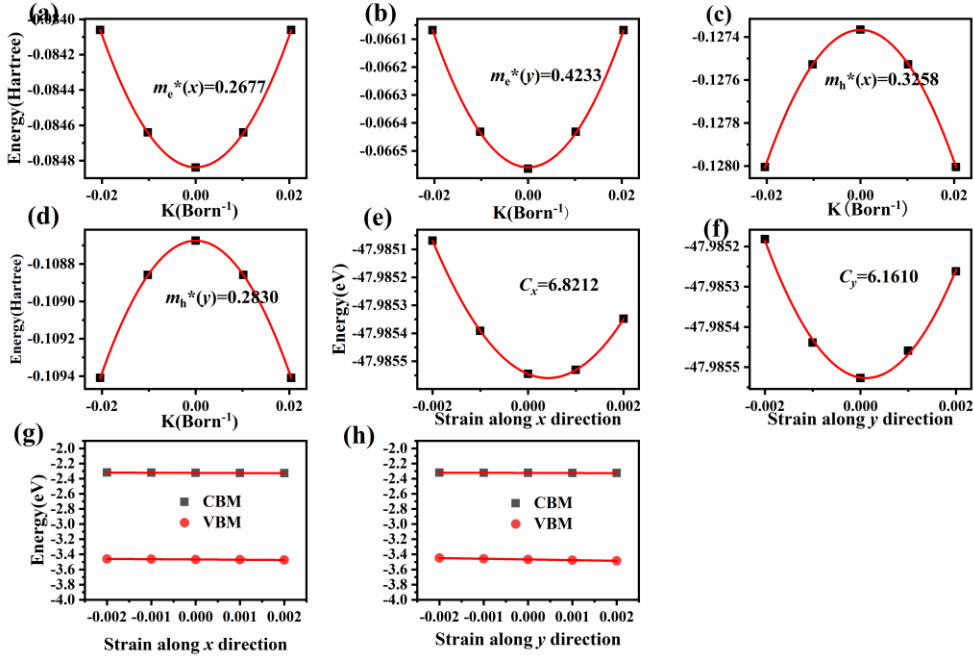
We calculated the carrier mobility of the three monolayers using the deformation potential (DP) theory 错误!未找到引用源。. The equation is <sup>8-11</sup>

$$\mu = \frac{2e\hbar^3 C}{3k_B T |m^*|^2 E_d^2} \quad (1)$$

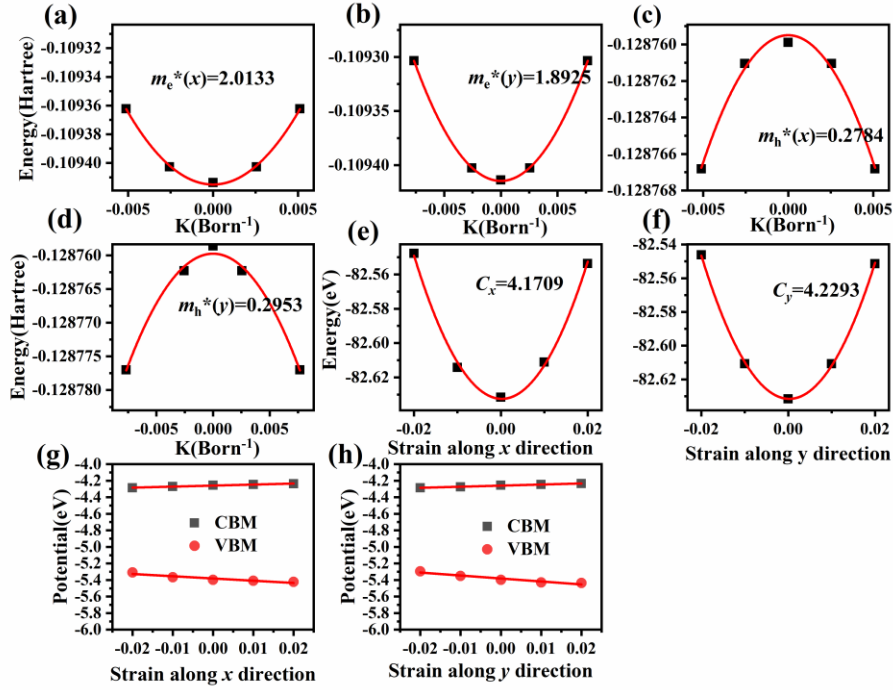
Where the carrier mobility  $\mu$  depends on the elastic modulus  $C$ , effective mass  $m^*$ , and deformation potential constant  $E_d$ .  $e$ ,  $\hbar$ ,  $k_B$ , and  $T$  are the electron charge, the reduced Planck constant, the Boltzmann constant,  $T$  is the temperature was set as 300 K.  $C$ ,  $m^*$ ,  $E_d$ , defined as  $C = \frac{1}{S_0} \frac{\partial^2 E}{\partial \varepsilon^2}$ ,  $\frac{1}{m^*} = \frac{1}{\hbar} \frac{\partial^2 E(k)}{\partial k^2}$ ,  $E_d = \frac{\partial E_{edge}}{\partial \varepsilon}$ , respectively. For the above equation  $C$ ,  $m^*$ ,  $E_d$ , where  $\varepsilon$  is the ratio of lattice parameter under the uniaxial strain along  $x$  or  $y$  direction on the rectangle cell,  $E$  is the total energy of the monolayer under uniaxial strains,  $S_0$  is the area of the monolayer, and  $E(k)$  is the energy corresponding to  $k$ ,  $k$  is the wave vector.  $E_{edge}$  is the energy of the band edge position calculated by HSE06. The detailed results are shown in Fig. S6–S8†.



**Fig. S6.** Fitting curve of elastic constant ( $C$ ), deformation potential constant ( $E_d$ ), and effective mass ( $m^*$ ) of HfSe<sub>2</sub> monolayer. (a) and (b) are the  $m^*$  fitting curves of the electrons along  $x$  and  $y$  directions, respectively. (c) and (d) are the  $m^*$  fitting curves of the holes along  $x$  and  $y$  directions, respectively. (e) and (f) are the fitting curves of  $C$  along the  $x$  and  $y$  directions, respectively. (g) and (h) are the fitting curves of  $E_d$  along  $x$  and  $y$  directions, respectively.



**Fig. S7.** Fitting curve of elastic constant ( $C$ ), deformation potential constant ( $E_d$ ), and effective mass ( $m^*$ ) of ZrSe<sub>2</sub> monolayer. (a) and (b) are the  $m^*$  fitting curves of the electrons along  $x$  and  $y$  directions, respectively. (c) and (d) are the  $m^*$  fitting curves of the holes along  $x$  and  $y$  directions, respectively. (e) and (f) are the fitting curves of  $C$  along the  $x$  and  $y$  directions, respectively. (g) and (h) are the fitting curves of  $E_d$  along  $x$  and  $y$  directions, respectively.



**Fig. S8.** Fitting curve of elastic constant ( $C$ ), deformation potential constant ( $E_d$ ), and effective mass ( $m^*$ ) of GaAs<sub>3</sub> monolayer. (a) and (b) are the  $m^*$  fitting curves of the electrons along  $x$  and  $y$  directions, respectively. (c) and (d) are the  $m^*$  fitting curves of the holes along  $x$  and  $y$  directions, respectively. (e) and (f) are the fitting curves of  $C$  along the  $x$  and  $y$  directions, respectively. (g) and (h) are the fitting curves of  $E_d$  along  $x$  and  $y$  directions, respectively.

**Table S2.** The elastic modulus ( $C$ ), deformation potential constant ( $E_d$ ), effective mass ( $m^*$ ) and carrier mobility ( $\mu$ ) for the HfSe<sub>2</sub>, ZrSe<sub>2</sub>, and GaAs<sub>3</sub> monolayers along with the  $x$  and  $y$  directions at 300 K.

Monolayer	Direction	Carrier	$C$ (N/m)	$E_d$ (eV)	$m^*$ ( $m_0$ )	$\mu$ ( $\text{cm}^2\text{V}^{-1}\text{s}^{-1}$ )
HfSe <sub>2</sub>	$x$	electron	107.60	0.86	0.24	36992.92
		hole	107.60	2.10	0.35	2907.25
	$y$	electron	103.16	1.29	0.29	10549.15
		hole	103.16	9.39	0.32	161.24
ZrSe <sub>2</sub>	$x$	electron	109.48	1.88	0.27	6126.36
		hole	109.48	3.45	0.42	727.58
	$y$	electron	98.88	1.40	0.33	6736.70
		hole	98.88	9.80	0.28	182.21
GaAs <sub>3</sub>	$x$	electron	68.28	1.23	0.25	10196.95
		hole	68.28	2.71	0.26	7896.72
	$y$	electron	67.52	1.31	1.80	193.81
		hole	67.52	3.59	1.69	26.02

### 3. Computational details for the optical properties and the solar-to-hydrogen conversion efficiency ( $\eta'_{\text{STH}}$ )

The equation of optical absorption coefficient  $\alpha(\omega)$  is<sup>12,13</sup>

$$\alpha(\omega) = \sqrt{2} \sqrt{\sqrt{\varepsilon_r^2(\omega) + \varepsilon_i^2(\omega)} - \varepsilon_r(\omega)} \quad (2)$$

Where  $\varepsilon_i(\omega)$  is the imaginary part of the complex dielectric function  $\varepsilon(\omega) = \varepsilon_r(\omega) + i\varepsilon_i(\omega)$ , can be calculated by the following equation<sup>14</sup>:

$$\varepsilon_i(\omega) = \frac{4\pi^2}{m^2\omega^2} \sum_{c,v} \int_{BZ} \frac{2}{(2\pi)^3} |M_{c,v}(k)|^2 \delta(\varepsilon_{ck} - \varepsilon_{vk} - \hbar\omega) d^3k \quad (3)$$

Where  $|M_{c,v}(k)|^2$  represent the momentum matrix element,  $c$  and  $v$  represent the conduction and valence band states, respectively.  $\varepsilon_i(\omega)$  can be calculated by VASP. The real part  $\varepsilon_r(\omega)$  can be calculated from the imaginary part  $\varepsilon_i(\omega)$  of the complex dielectric function by using the Kramer-Kroning relationship<sup>15</sup>.



The solar-to-hydrogen conversion efficiency ( $\eta_{\text{STH}}$ ) and solar-to-fuel ( $\eta_{\text{STF}}$ ) conversion efficiency is the result of the efficiency of light absorption  $\eta_{\text{abs}}$  and the efficiency of carrier utilization  $\eta_{\text{cu}}$ , which can be considered as the crucial factor in determining the catalytic ability of photocatalysts. We calculated  $\eta_{\text{STH/STF}}$ ,  $\eta_{\text{abs}}$ , and  $\eta_{\text{cu}}$  based on the following formula<sup>16</sup>:

$$\eta_{\text{STH/STF}} = \eta_{\text{abs}} \times \eta_{\text{cu}} \quad (4)$$

$$\eta_{\text{abs}} = \frac{\int_{E_g}^{\infty} P(h\omega) d(h\omega)}{\int_0^{\infty} P(h\omega) d(h\omega)} \quad (5)$$

$$\eta_{\text{cu}} = \frac{\Delta G \int_E^{\infty} \frac{P(h\omega)}{h\omega} d(h\omega)}{\int_{E_g}^{\infty} P(h\omega) d(h\omega)} \quad (6)$$

$$E = \begin{cases} E_g, & (\chi(\text{H}_2) \geq 0.2, \chi(\text{O}_2) \geq 0.6) \\ E_g + 0.2 - \chi(\text{H}_2), & (\chi(\text{H}_2) < 0.2, \chi(\text{O}_2) \geq 0.6) \\ E_g + 0.6 - \chi(\text{O}_2), & (\chi(\text{H}_2) \geq 0.2, \chi(\text{O}_2) < 0.6) \\ E_g + 0.8 - \chi(\text{H}_2) - \chi(\text{O}_2), & (\chi(\text{H}_2) < 0.2, \chi(\text{O}_2) < 0.6) \end{cases} \quad (7)$$

Where  $P(h\omega)$  is the AM1.5G solar energy flux at the photo energy  $h\omega$ ;  $E_g$  (HSE) is the bandgap of the layer materials;  $\chi(\text{H}_2)$  and  $\chi(\text{O}_2)$  are the overpotentials for hydrogen and oxygen evolution reactions, respectively.  $\Delta G$  represents the potential difference of 1.23 eV for water splitting or 1.06 eV for  $\text{CO}_2$  conversion into  $\text{CH}_4$  using  $\text{H}_2\text{O}$  as electron donor, and  $E$  is the energy of photons that can actually be utilized for water splitting.

Because the intrinsic electric field would promote the electron-hole separation, so the corrected STH/STF efficiency ( $\eta'_{\text{STH/STF}}$ ) for polarized materials in photocatalytic water splitting reaction can be calculated as:

$$\eta'_{\text{STH/STF}} = \eta_{\text{STH/STF}} \times \frac{\int_0^{\infty} P(h\omega) d(h\omega)}{\int_0^{\infty} P(h\omega) d(h\omega) + \Delta\Phi \int_0^{\infty} P(h\omega) d(h\omega)} \quad (8)$$

Where  $\Delta\Phi$  is the vacuum level difference between the two respectively surfaces of the polarized material.

**Table S3.** The energy conversion efficiency of the light absorption of light ( $\eta_{\text{abs}}$ ), carrier utilization ( $\eta_{\text{cu}}$ ),  $\eta'_{\text{STH}}$  and  $\eta'_{\text{STF}}$  of the HfSe<sub>2</sub>/GaAs<sub>3</sub> heterostructure.

HfSe <sub>2</sub> /GaAs <sub>3</sub>	$E_{\text{g-HfSe}_2}$ (eV)	$E_{\text{g-GaAs}_3}$ (eV)	$\chi(\text{H}_2)$ (eV)	$\chi(\text{O}_2)$ (eV)	$\chi(\text{CO}_2)$ (eV)	$\Delta\phi$ (eV)	$\eta_{\text{abs}}$ (%)	$\eta_{\text{cu}}$ (%)	$\eta'_{\text{STH}}$ (%)	$\eta'_{\text{STF}}$ (%)
-3%	0.96	0.88	0.13	0.19	0.30	0.03	91.31	42.96	38.62	34.99
-2%	1.08	1.00	0.16	0.28	0.33	0.05	84.83	47.36	39.29	33.37
-1%	1.19	1.11	0.20	0.39	0.37	0.06	79.00	52.01	40.54	33.45
0%	1.31	1.23	0.24	0.49	0.41	0.08	73.37	55.35	39.45	32.47
1%	1.39	1.30	0.27	0.56	0.44	0.09	70.23	50.73	39.06	32.00
2%	1.47	1.38	0.29	0.65	0.46	0.10	64.96	58.15	36.65	30.31
3%	1.55	1.39	0.32	0.73	0.49	0.11	60.47	56.44	33.12	27.31
4%	1.63	1.39	0.34	0.82	0.51	0.10	56.51	54.96	30.29	24.71

**Table S4.** The energy conversion efficiency of the light absorption of light ( $\eta_{\text{abs}}$ ), carrier utilization ( $\eta_{\text{cu}}$ ),  $\eta'_{\text{STH}}$  and  $\eta'_{\text{STF}}$  of the ZrSe<sub>2</sub>/GaAs<sub>3</sub> heterostructure.

ZrSe <sub>2</sub> /GaAs <sub>3</sub>	$E_{\text{g-GaAs}_3}$ (eV)	$E_{\text{g-ZrSe}_2}$ (eV)	$\chi(\text{H}_2)$ (eV)	$\chi(\text{O}_2)$ (eV)	$\chi(\text{CO}_2)$ (eV)	$\Delta\phi$ (eV)	$\eta_{\text{abs}}$ (%)	$\eta_{\text{cu}}$ (%)	$\eta'_{\text{STH}}$ (%)	$\eta'_{\text{STF}}$ (%)
-3%	0.98	0.81	0.15	0.24	0.32	0.05	90.40	46.83	41.10	35.75
-2%	1.09	0.92	0.19	0.33	0.36	0.03	84.51	50.68	42.25	35.38
-1%	1.18	1.02	0.21	0.43	0.38	0.02	80.32	54.55	43.45	35.93
0%	1.30	1.04	0.25	0.52	0.42	0	73.66	57.98	42.71	35.12
1%	1.36	1.21	0.28	0.60	0.45	0	71.35	60.61	43.25	35.85
2%	1.52	1.29	0.45	0.67	0.62	0.02	62.35	57.14	35.42	29.12
3%	1.51	1.36	0.46	0.74	0.63	0.03	62.80	57.31	35.68	29.42
4%	1.60	1.43	0.57	0.81	0.74	0.04	57.77	55.43	31.69	25.91

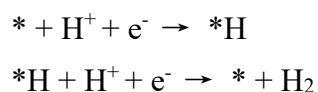
#### 4. Calculational method of the Gibbs free energy.

The  $\Delta G$  can be calculated by the following equation<sup>17-20</sup>:

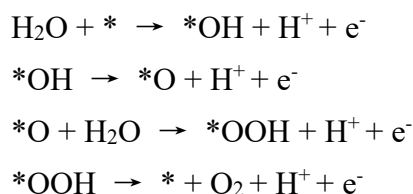
$$\Delta G = \Delta E - T\Delta S - \Delta E_{\text{ZPE}} \quad (9)$$

Where  $\Delta E$ ,  $\Delta E_{\text{ZPE}}$  and  $\Delta S$  represent the differences in total energy, zero-point energy and entropy of the slab with and without adsorbed intermediates. T is the temperature 298K. The  $E_{\text{ZPE}}$  can be calculated by  $E_{\text{ZPE}} = \frac{1}{2}\sum\hbar\nu$ , where the  $\nu$  is the vibrational frequency over normal modes, and the zero-point of slab can be negligible. The entropies of the free molecules were taken from the standard tables in Physical chemistry and that of intermediates were obtained from vibrational frequency. For those reactions involving the release of protons and electrons, the free energy of one pair of proton and electron ( $\text{H}^+/\text{e}^-$ ) was taken as  $1/2G_{\text{H}_2}$ .

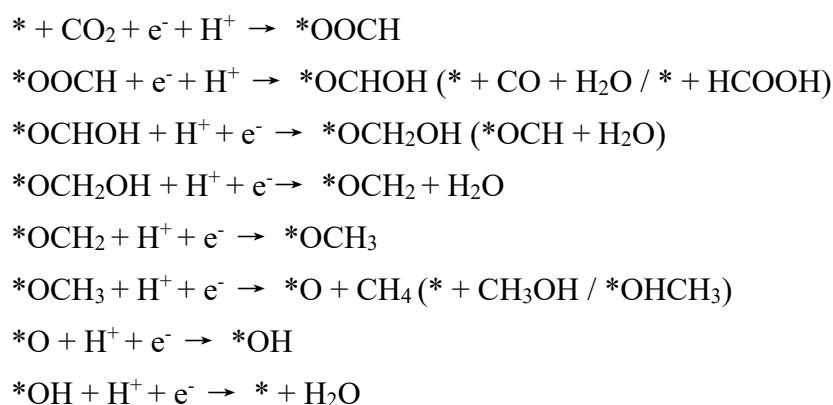
In the aqueous solution, the HER with two electrons pathway, which can be written as:



The OER process can be written as:



The  $\text{CO}_2\text{RR}$  process with eight-electron pathway which can be written as:



**Table. S5** The calculated total energies of the \*H, \*OOCH, and \*COOH absorbed on Ga or As atoms of HfSe<sub>2</sub>/GaAs<sub>3</sub> and ZrSe<sub>2</sub>/GaAs<sub>3</sub> heterostructures optimized by the *k*-points of 1 × 1 × 1.

		Intermediates	energy			Intermediates	energy
		*H(Ga)	-533.4396			*H(Ga)	-467.2749
		*H(As)	-533.5221			*H(As)	-467.3630
HfSe <sub>2</sub> /GaAs <sub>3</sub>	*OOCH(Ga)	-557.5166	ZrSe <sub>2</sub> /GaAs <sub>3</sub>	*OOCH(Ga)	-491.2834		
	*COOH(Ga)	-556.7326		*COOH(Ga)	-490.4588		
	*OOCH(As)	-556.3622		*OOCH(As)	-490.2043		
	*COOH(As)	-556.5328		*COOH(As)	-490.2940		

**Table. S5** The calculated ZPE, TS, and the  $\Delta G$ s for the adsorbed molecules of HfSe<sub>2</sub>/GaAs<sub>3</sub> configuration.

HfSe <sub>2</sub> /GaAs <sub>3</sub>	ZPE (eV)	TS (eV)	$\Delta G$ (eV)
*OH(OER)	0.3172	0.1081	2.3506
*O(OER)	0.0594	0.0872	1.0456
*OOH(OER)	0.4292	0.1519	2.0967
*H	0.1903	0.0168	0.3530
*COOH	0.6105	0.2354	0.6292
*OOCH	0.6145	0.2427	-0.1523
*OCHOH	0.9115	0.1889	0.4301
*OCH	0.4969	0.1064	0.5351
CO	0.1330	0.6110	0.5433
HCOOH	0.8860	0.7690	0.4463
*OCH <sub>2</sub> OH	1.2367	0.2354	0.1598
*OCH <sub>2</sub>	0.7799	0.1604	-0.3483
*OCH <sub>3</sub>	1.0851	0.0962	-0.1849
*OHCH <sub>3</sub>	1.4083	0.1323	-0.3971
CH <sub>3</sub> OH	1.3450	0.7410	-0.1519
*O(CO <sub>2</sub> RR)	0.0759	0.0400	-0.7286
*OH(CO <sub>2</sub> RR)	0.3329	0.1519	-0.4862

**Table. S6** The calculated ZPE, TS, and the  $\Delta G$ s for the adsorbed molecules of ZrSe<sub>2</sub>/GaAs<sub>3</sub> configuration.

ZrSe <sub>2</sub> /GaAs <sub>3</sub>	ZPE (eV)	TS (eV)	$\Delta G$ (eV)
*OH(OER)	0.3210	0.1125	2.2163
*O(OER)	0.0576	0.0957	1.0513
*OOH(OER)	0.4307	0.1500	2.1662
*H	0.1898	0.0173	0.2653
*COOH	0.6096	0.2326	0.7015
*OOCH	0.6095	0.2418	-0.1044
*OCHOH	0.9214	0.2188	0.3821
*OCH	0.4981	0.1046	0.5175
CO	0.1330	0.6110	0.4953
HCOOH	0.8860	0.7690	0.3983
*OCH <sub>2</sub> OH	1.2065	0.1806	0.3600
*OCH <sub>2</sub>	0.7466	0.1233	-0.4243
*OCH <sub>3</sub>	1.0850	0.1596	-0.3218
CH <sub>3</sub> OH	1.3450	0.7410	-0.1237
*OHCH <sub>3</sub>	1.4177	0.2142	-0.4270
*O(CO <sub>2</sub> RR)	0.0756	0.0493	-0.7089
*OH(CO <sub>2</sub> RR)	0.3268	0.0997	-0.3894

## References

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